

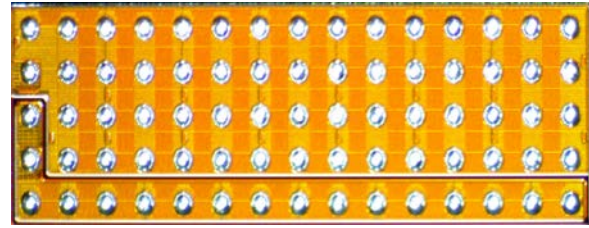
EPC2100 – Enhancement Mode GaN Power Transistor Half Bridge Preliminary Specification Sheet

Features:

- 90% System Efficiency at 25 A
 - o 12 V_{IN} to 1.2V_{OUT}, 500 kHz
 - o Includes output filter
- High Frequency Operation (Beyond 10 MHz)
- High Density Footprint
- Low Inductance Package
- Pb-Free (RoHS Compliant), Halogen Free

Applications:

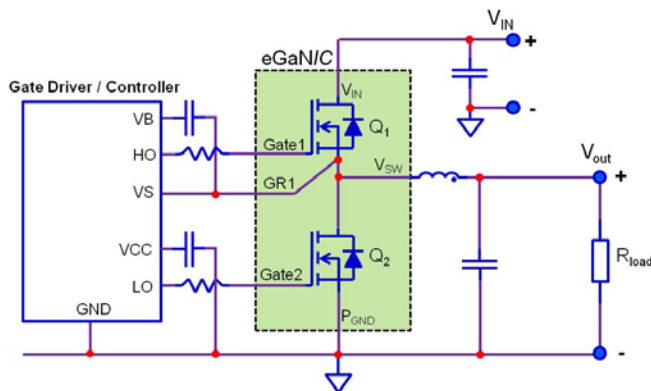
- High Frequency DC-DC Conversion
- Point-of-Load (POL) Converters



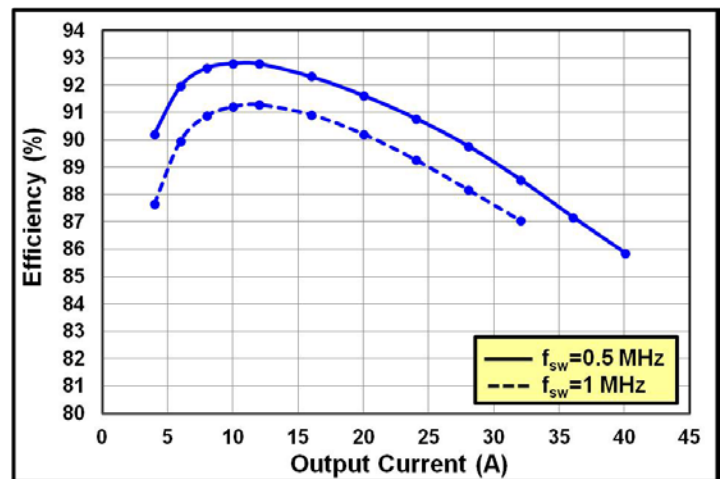
EPC2100 devices are supplied only in passivated die form with solder bars

Die Size: 6.05 mm x 2.3 mm

Typical Circuit



Typical System Efficiency



MAXIMUM RATINGS

Parameter		Value
Maximum Drain – Source Voltage (V _{SW} to P _{GND} , V _{IN} to V _{SW})		30 V
Maximum Gate – Source Voltage Range (Gate 1 to V _{SW} , Gate 2 to P _{GND})		-4 V < V _{GS} < 6 V
Continuous Drain Current, 25 °C	Q1 Control FET	9.5 A
	Q2 Sync FET	38 A
Maximum Pulsed Drain Current, 25 °C, T _{pulse} = 300 μs	Q1 Control FET	100 A
	Q2 Sync FET	400 A
Optimum Temperature Range		-40 °C < T _J < 150 °C

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STATIC CHARACTERISTICS

Parameter	Conditions	Q1 Control FET	Q2 Sync FET
Maximum Drain – Source Voltage (BV_{DSS})	Q1: $V_{GS} = 0\text{ V}$, $I_D = 250\text{ }\mu\text{A}$	30 V	
	Q2: $V_{GS} = 0\text{ V}$, $I_D = 1\text{ mA}$		
Maximum Drain – Source Leakage	$V_{DS} = 24\text{ V}$, $V_{GS} = 0\text{ V}$	200 μA	800 μA
Maximum $R_{DS(ON)}$	$V_{GS} = 5\text{ V}$, $I_D = 25\text{ A}$	8 m Ω	2 m Ω
Typical $R_{DS(ON)}$	$V_{GS} = 5\text{ V}$, $I_D = 25\text{ A}$	6 m Ω	1.5 m Ω
Gate – Source Threshold Voltage	Q1: $I_D = 4\text{ mA}$, $V_{DS} = V_{GS}$	0.8 V < $V_{GS(TH)}$ < 2.5 V	
	Q2: $I_D = 16\text{ mA}$, $V_{DS} = V_{GS}$		
Gate – Source Maximum Positive Leakage	$V_{GS} = 5\text{ V}$	3 mA	9 mA
Gate – Source Maximum Negative Leakage	$V_{GS} = -4\text{ V}$	-200 μA	-800 μA

$T_J = 25\text{ }^\circ\text{C}$ unless otherwise stated

DYNAMIC CHARACTERISTICS

Parameter	Conditions	Typical Value		
		Q1 Control FET	Q2 Sync FET	Unit
C_{ISS} (Input Capacitance)	$V_{DS} = 15\text{ V}$, $V_{GS} = 0\text{ V}$	380	1700	pF
C_{OSS} (Output Capacitance)		290	1600	
C_{RSS} (Reverse Transfer Capacitance)		20	110	
Q_G (Total Gate Charge)	$V_{DS} = 15\text{ V}$, $I_D = 25\text{ A}$	3.5	15	nC
Q_{GS} (Gate to Source Charge)		1.4	4.6	
Q_{GD} (Gate to Drain Charge)		0.57	2.6	
$Q_{G(TH)}$ (Gate Charge at Threshold)		0.90	3.4	
Q_{OSS} (Output Charge)	$V_{DS} = 15\text{ V}$, $V_{GS} = 0\text{ V}$	5.5	28	nC
Q_{RR} (Source-Drain Recovery Charge)		0	0	

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THERMAL CHARACTERISTICS

		TYP		
		Q1 Control FET	Q2 Sync FET	
$R_{\theta JC}$	Thermal Resistance, Junction to Case	0.4		°C/W
$R_{\theta JB}$	Thermal Resistance, Junction to Board (Note 2)	1.8	1.2	°C/W
$R_{\theta 12}$	Thermal Resistance, Cross-Coupling	0.85		°C/W
$R_{\theta JA}$	Thermal Resistance, Junction to Ambient (Note 1)	42		°C/W

Note 1: $R_{\theta JA}$ is determined with the device mounted on one square inch of copper pad, single layer 2 oz copper on FR4 board.

Note 2: ΔT is determined by the following matrix equation:

$$\begin{pmatrix} \Delta T_{Q1} \\ \Delta T_{Q2} \end{pmatrix} = \begin{bmatrix} 1.2 & 0.85 \\ 0.85 & 1.8 \end{bmatrix} \cdot \begin{pmatrix} P_{Q1} \\ P_{Q2} \end{pmatrix}$$

This matrix equation lets you calculate the temperature rise of each FET, given the power dissipated in each FET.

Thermal models for EPC devices available at <http://epc-co.com/epc/DesignSupport/DeviceModels.aspx>

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Figure 1a:

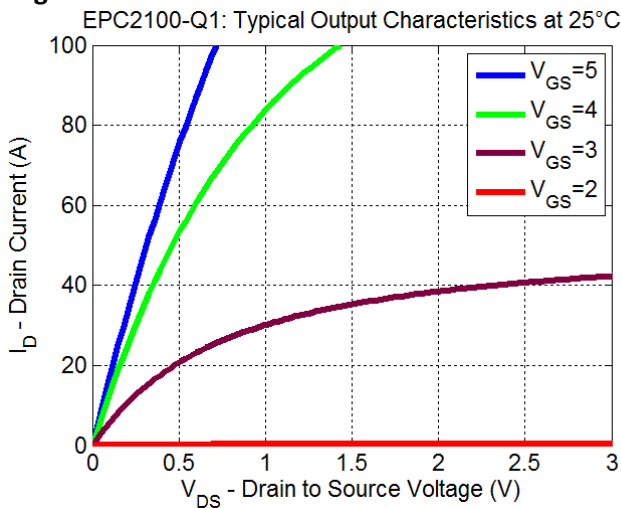


Figure 1b:

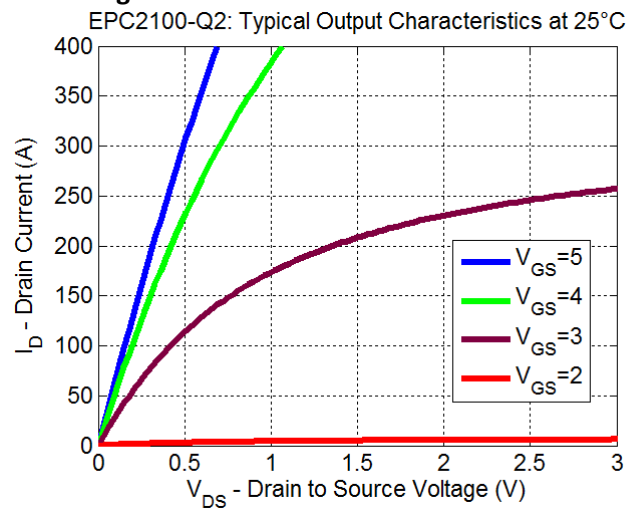


Figure 2a:

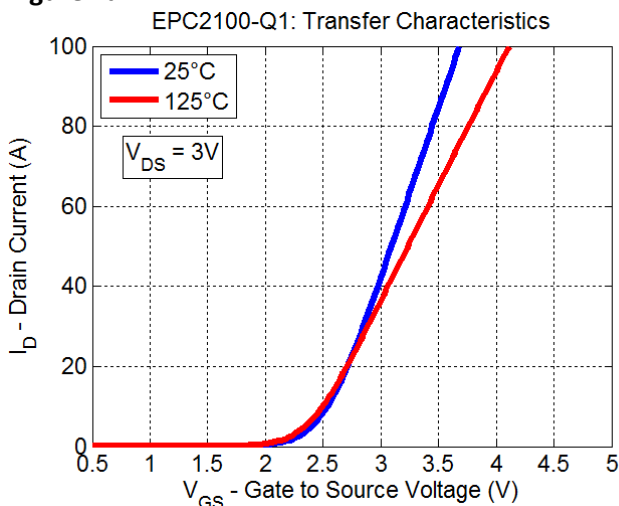


Figure 2b:

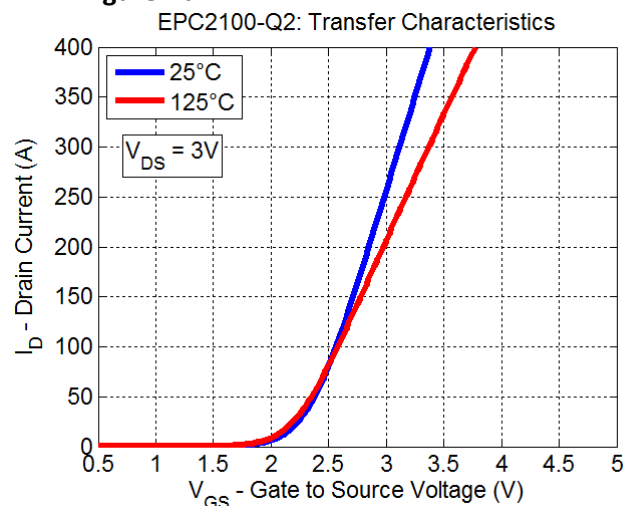


Figure 3a:

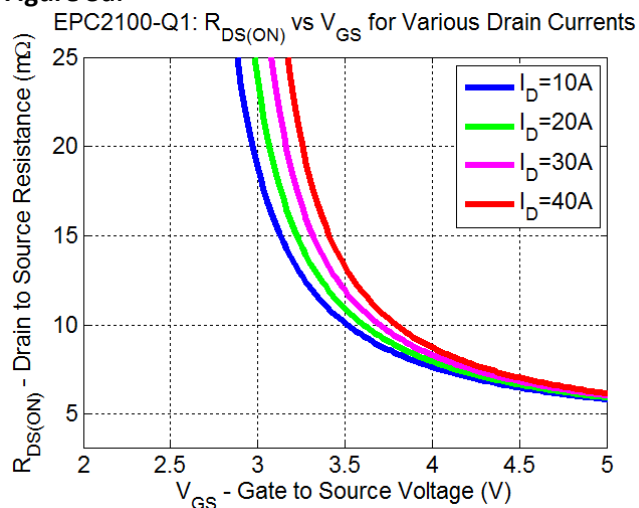
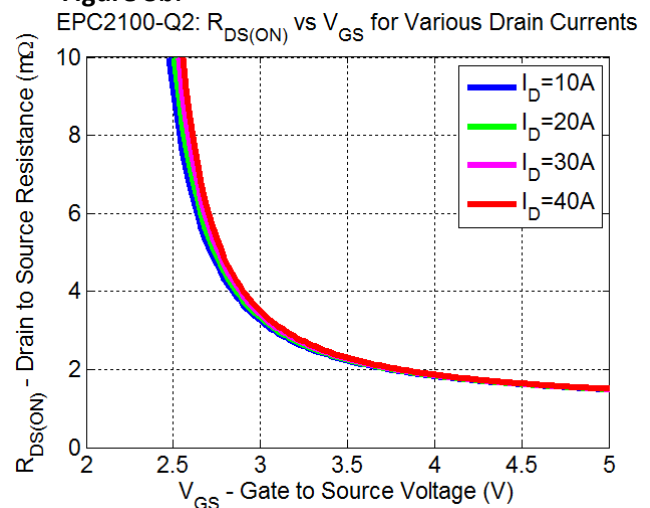


Figure 3b:



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Figure 4a:

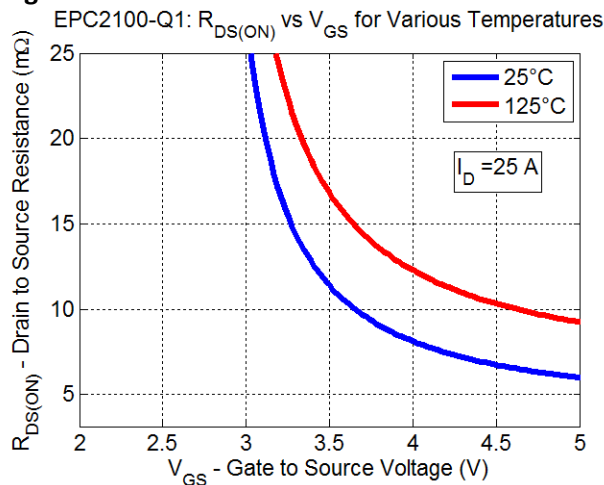


Figure 4b:

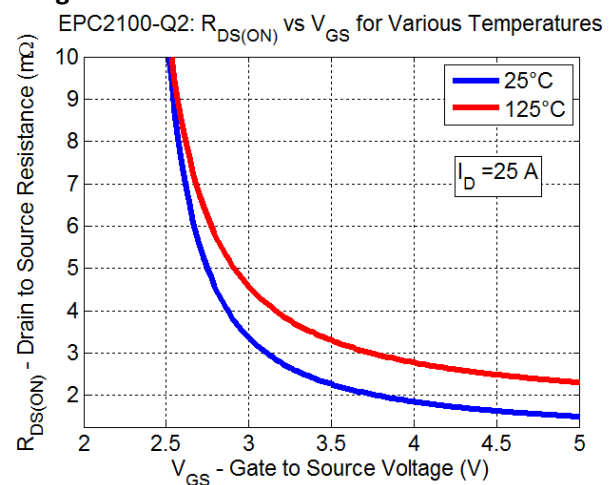


Figure 5a:

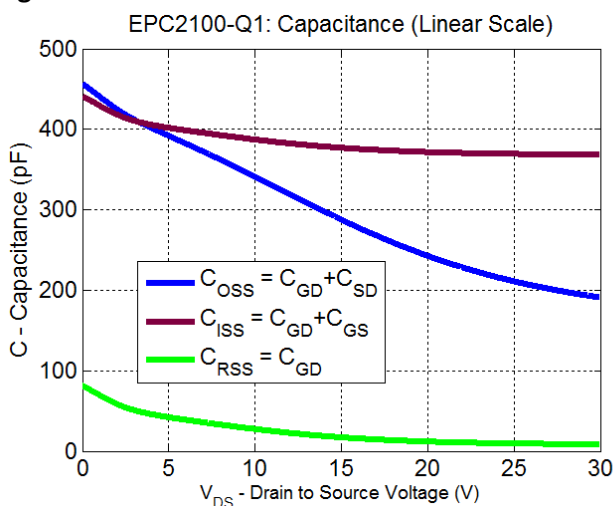


Figure 5b:

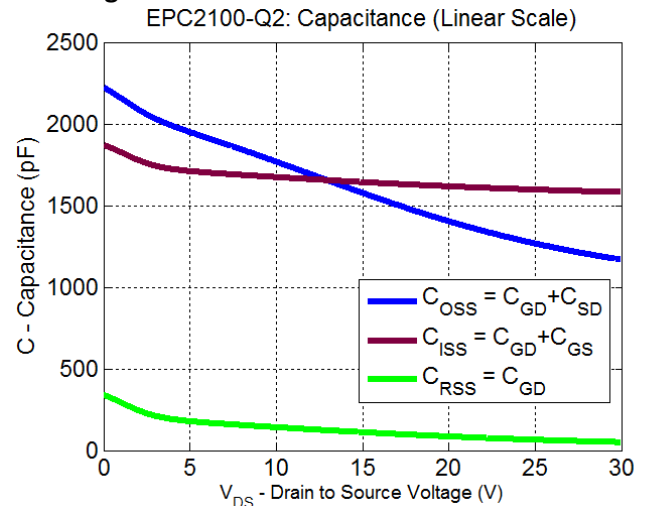


Figure 5c:

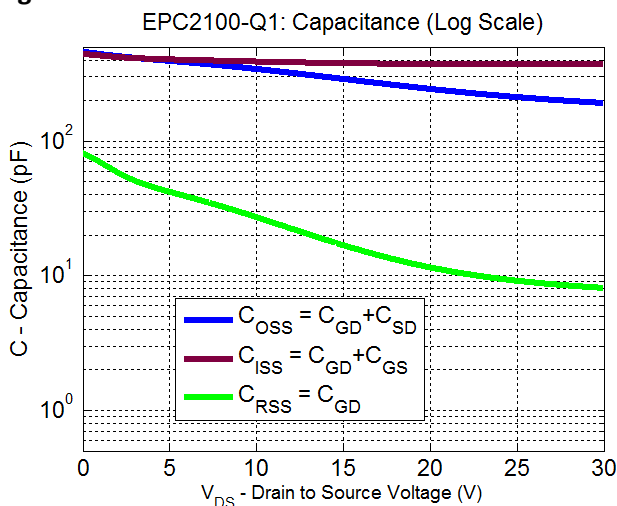
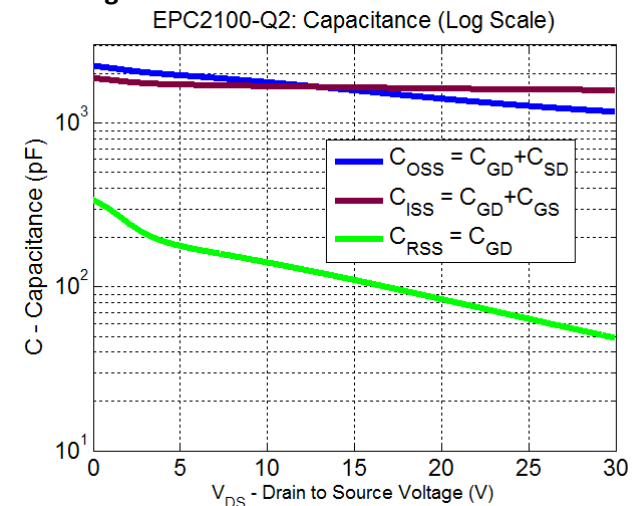


Figure 5d:



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Figure 6a:

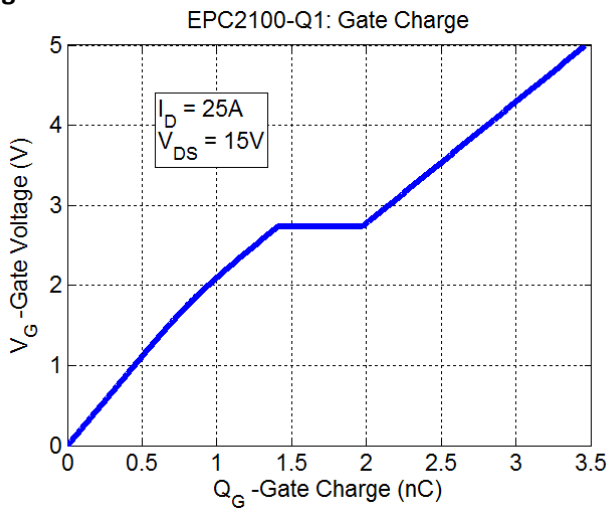


Figure6b:

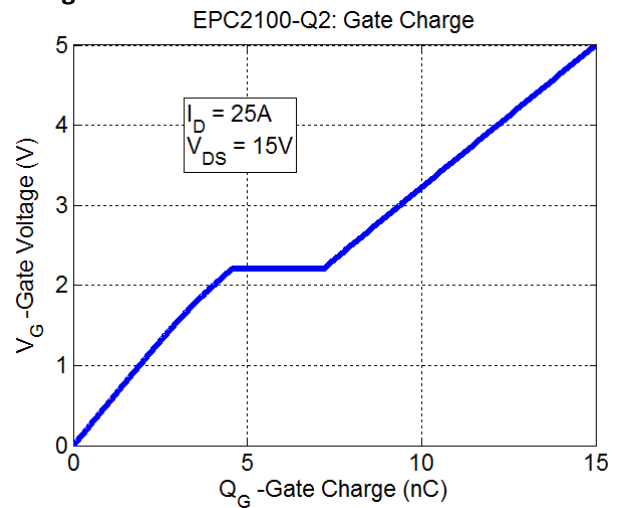


Figure 7a:

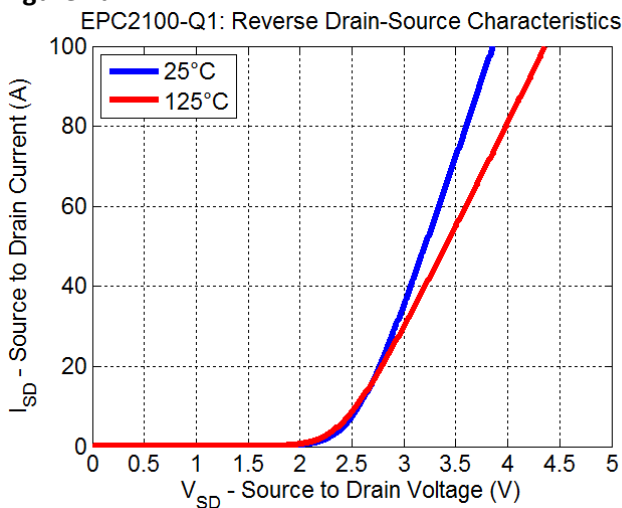


Figure7b:

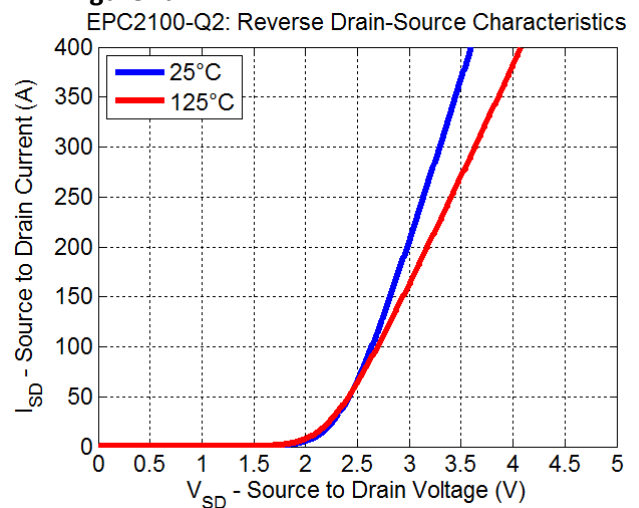


Figure 8a:

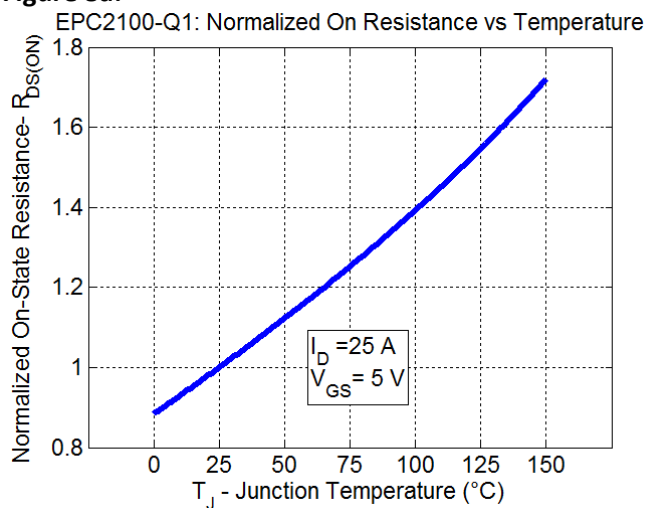
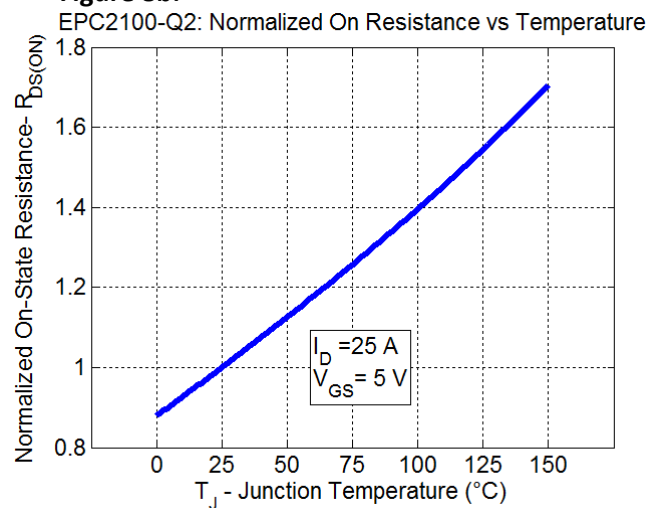


Figure 8b:



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Figure 9a:

EPC2100-Q1: Normalized Threshold Voltage vs Temperature

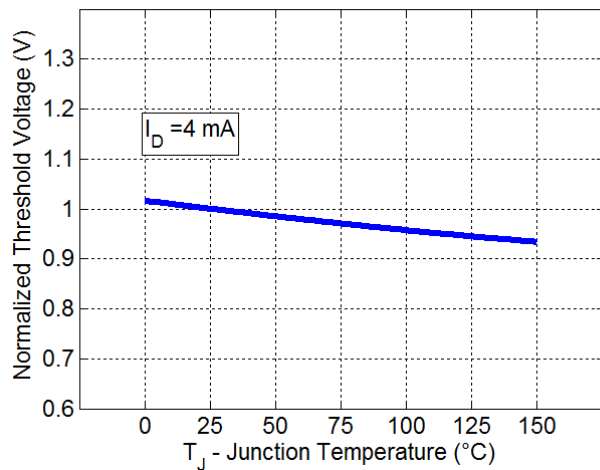
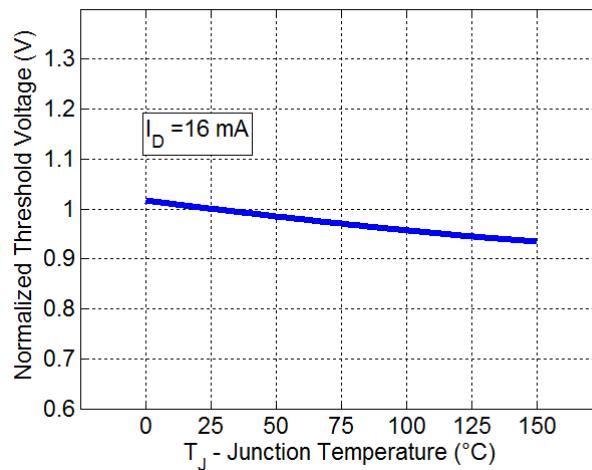


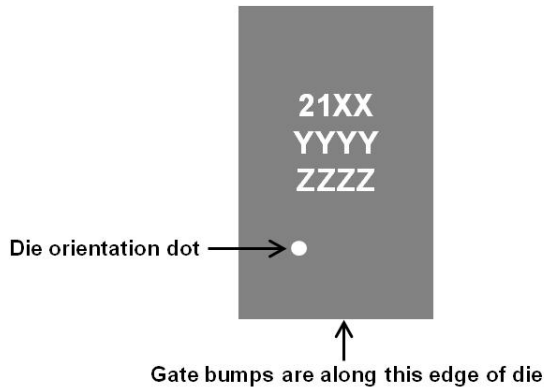
Figure 9b:

EPC2100-Q2: Normalized Threshold Voltage vs Temperature



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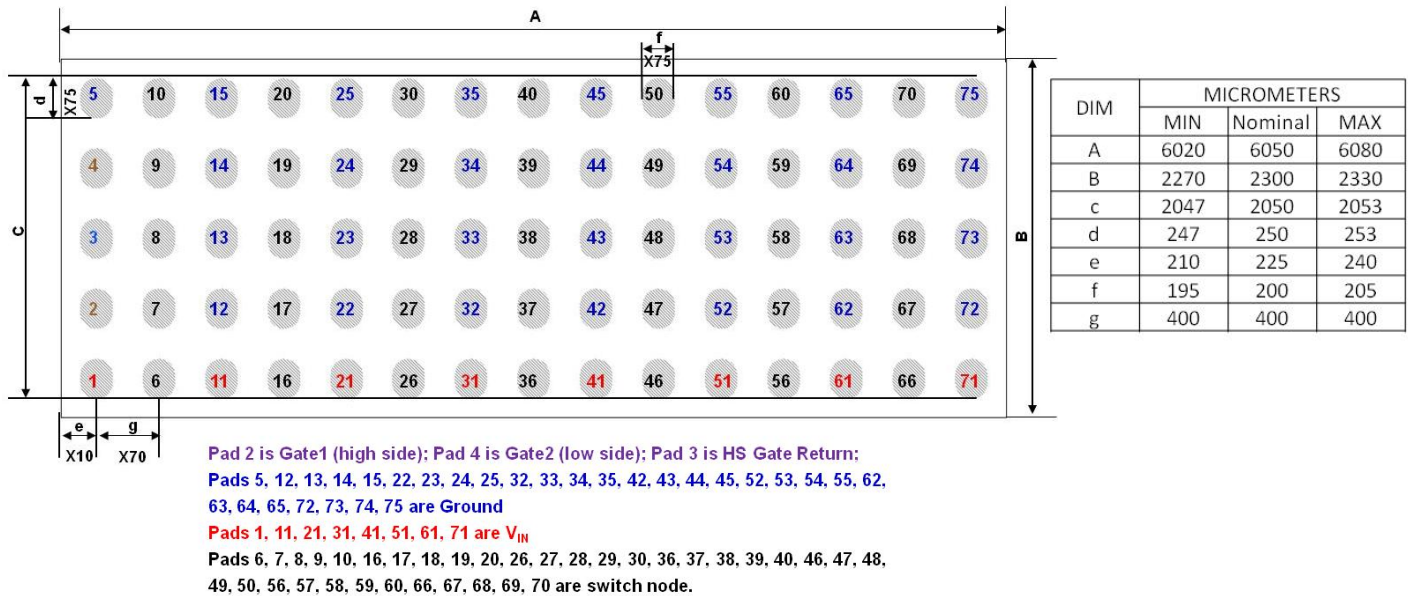
DIE MARKINGS



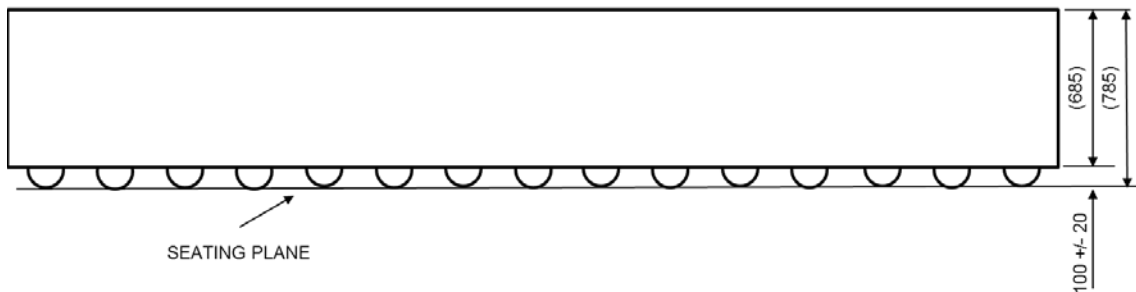
Part Number	Laser Marking		
	Part # Marking Line 1	Lot_Date Code Marking Line 2	Lot_Date Code Marking Line 3
EPC2100ENGR	21XX	YYYY	ZZZZ

DIE OUTLINE

Solder Bar View



Side View

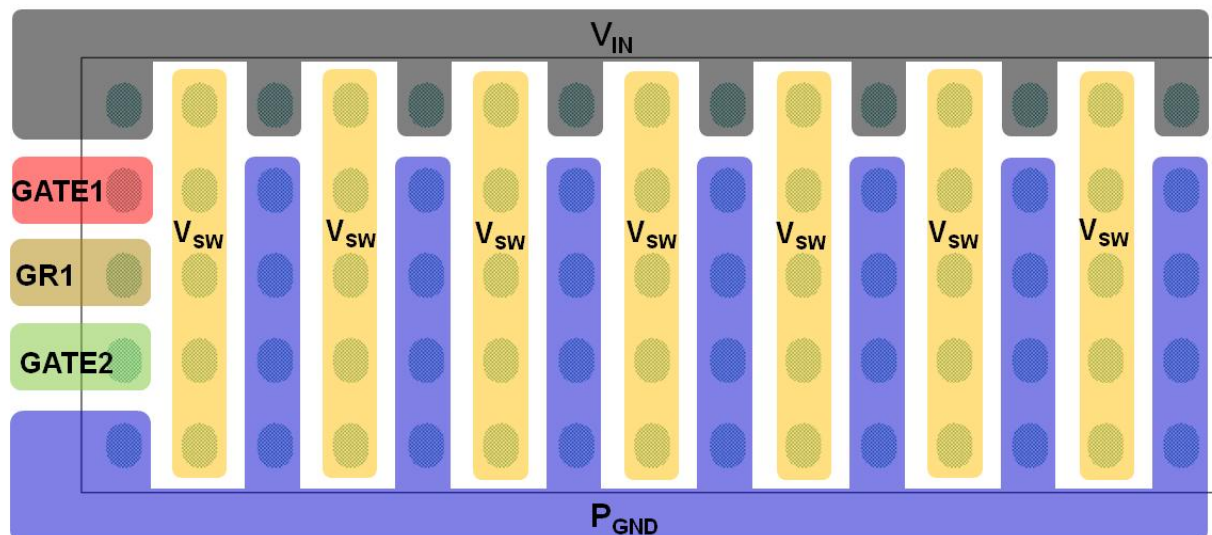


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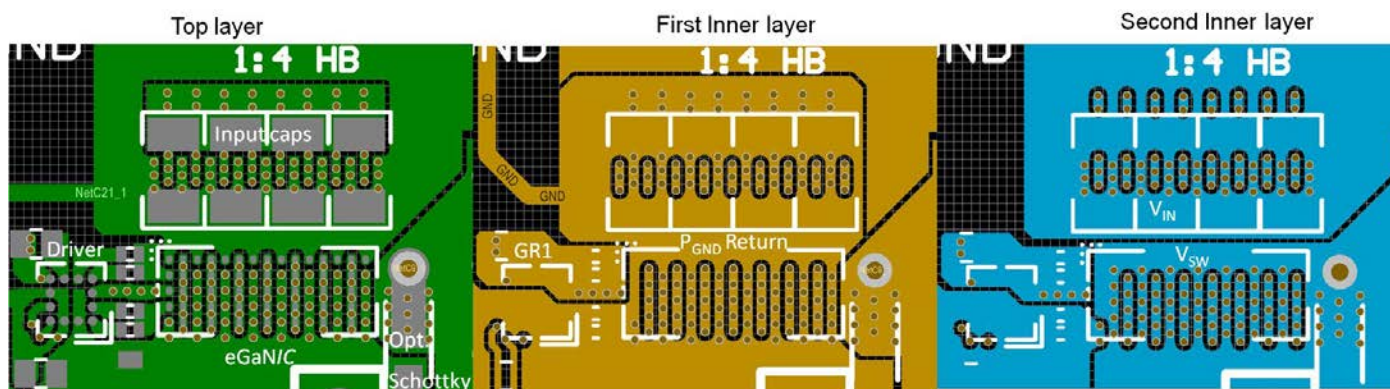
RECOMMENDED LAND PATTERN

(Units in μm)



Land pattern is solder mask defined.

LAYOUT EXAMPLE



Recommended PCB Layout

Gerber Files available at:

<http://epc-co.com/epc/documents/gerber-files/EPC9036%20Development%20Board%20Gerbers.zip>

Assembly Resources at: <http://epc-co.com/epc/DesignSupport/AssemblyBasics.aspx>

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U.S. Patents 8,350,294; 8,404,508; 8,431,960; 8,436,398; 8,785,974; 8,890,168; 8,969,918; 8,853,749; 8,823,012

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